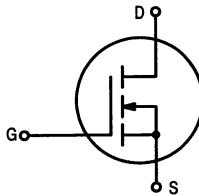


The RF MOSFET Line  
**RF Power Field-Effect Transistor**  
**N-Channel Enhancement-Mode MOSFET**

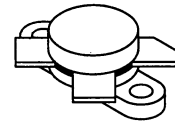
... designed for broadband commercial and military applications at frequencies to 175 MHz. The high power, high gain and broadband performance of this device makes possible solid state transmitters for FM broadcast or TV channel frequency bands.

- Guaranteed Performance at 30 MHz, 28 V:  
 Output Power — 150 W  
 Gain — 18 dB (22 dB Typ)  
 Efficiency — 40%
- Typical Performance at 175 MHz, 50 V:  
 Output Power — 150 W  
 Gain — 13 dB
- Low Thermal Resistance
- Ruggedness Tested at Rated Output Power
- Nitride Passivated Die for Enhanced Reliability



**MRF141**

**150 W, 28 V, 175 MHz**  
**N-CHANNEL**  
**BROADBAND**  
**RF POWER MOSFET**



**CASE 211-11, STYLE 2**

**MAXIMUM RATINGS**

Rating	Symbol	Value	Unit
Drain-Source Voltage	$V_{DSS}$	65	Vdc
Drain-Gate Voltage	$V_{DGO}$	65	Vdc
Gate-Source Voltage	$V_{GS}$	$\pm 40$	Vdc
Drain Current — Continuous	$I_D$	16	Adc
Total Device Dissipation @ $T_C = 25^\circ\text{C}$ Derate above $25^\circ\text{C}$	$P_D$	300 1.71	Watts W/ $^\circ\text{C}$
Storage Temperature Range	$T_{stg}$	-65 to +150	$^\circ\text{C}$
Operating Junction Temperature	$T_J$	200	$^\circ\text{C}$

**THERMAL CHARACTERISTICS**

Characteristic	Symbol	Max	Unit
Thermal Resistance, Junction to Case	$R_{\theta JC}$	0.6	$^\circ\text{C/W}$

**NOTE — CAUTION** — MOS devices are susceptible to damage from electrostatic charge. Reasonable precautions in handling and packaging MOS devices should be observed.

**ELECTRICAL CHARACTERISTICS** ( $T_C = 25^\circ\text{C}$  unless otherwise noted.)

Characteristic	Symbol	Min	Typ	Max	Unit
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**OFF CHARACTERISTICS (1)**

Drain-Source Breakdown Voltage ( $V_{GS} = 0, I_D = 100 \text{ mA}$ )	$V_{(BR)DSS}$	65	—	—	Vdc
Zero Gate Voltage Drain Current ( $V_{DS} = 28 \text{ V}, V_{GS} = 0$ )	$I_{DSS}$	—	—	5.0	mAdc
Gate-Body Leakage Current ( $V_{GS} = 20 \text{ V}, V_{DS} = 0$ )	$I_{GSS}$	—	—	1.0	$\mu\text{Adc}$

**ON CHARACTERISTICS (1)**

Gate Threshold Voltage ( $V_{DS} = 10 \text{ V}, I_D = 100 \text{ mA}$ )	$V_{GS(th)}$	1.0	3.0	5.0	Vdc
Drain-Source On-Voltage ( $V_{GS} = 10 \text{ V}, I_D = 10 \text{ A}$ )	$V_{DS(on)}$	—	—	1.5	Vdc
Forward Transconductance ( $V_{DS} = 10 \text{ V}, I_D = 5.0 \text{ A}$ )	$g_{fs}$	5.0	7.0	—	mhos

**DYNAMIC CHARACTERISTICS (1)**

Input Capacitance ( $V_{DS} = 28 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{iss}$	—	350	—	pF
Output Capacitance ( $V_{DS} = 28 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{oss}$	—	420	—	pF
Reverse Transfer Capacitance ( $V_{DS} = 28 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{rss}$	—	40	—	pF

**FUNCTIONAL TESTS**

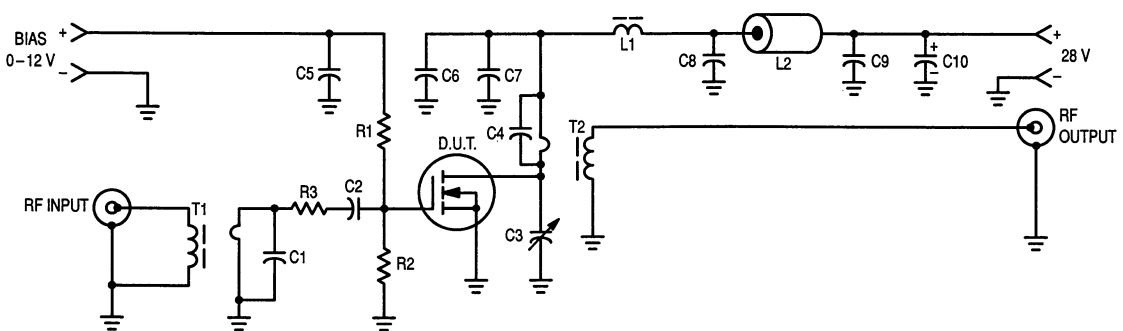
Common Source Amplifier Power Gain, $f = 30; 30.001 \text{ MHz}$ ( $V_{DD} = 28 \text{ V}, P_{out} = 150 \text{ W (PEP)}, I_{DQ} = 250 \text{ mA}$ ) $f = 175 \text{ MHz}$	$G_{ps}$	16 —	20 10	— —	dB
Drain Efficiency ( $V_{DD} = 28 \text{ V}, P_{out} = 150 \text{ W (PEP)}, f = 30; 30.001 \text{ MHz},$ $I_{DQ} = 250 \text{ mA}, I_D (\text{Max}) = 5.95 \text{ A}$ )	$\eta$	40	45	—	%
Intermodulation Distortion (1) ( $V_{DD} = 28 \text{ V}, P_{out} = 150 \text{ W (PEP)}, f = 30 \text{ MHz},$ $f_2 = 30.001 \text{ MHz}, I_{DQ} = 250 \text{ mA}$ )	IMD(d3) IMD(d11)	— —	-30 -60	-28 —	dB
Load Mismatch ( $V_{DD} = 28 \text{ V}, P_{out} = 150 \text{ W (PEP)}, f_1 = 30; 30.001 \text{ MHz},$ $I_{DQ} = 250 \text{ mA}, \text{VSWR } 30:1 \text{ at all Phase Angles}$ )	$\psi$	No Degradation in Output Power			

**CLASS A PERFORMANCE**

Intermodulation Distortion (1) and Power Gain ( $V_{DD} = 28 \text{ V}, P_{out} = 50 \text{ W (PEP)}, f_1 = 30 \text{ MHz},$ $f_2 = 30.001 \text{ MHz}, I_{DQ} = 4.0 \text{ A}$ )	$G_{PS}$ IMD(d3) IMD(d9-13)	— — —	23 -50 -75	— — —	dB
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**NOTE:**

- To MIL-STD-1311 Version A, Test Method 2204B, Two Tone, Reference Each Tone.



- C1 — 820 pF Dipped Mica
- C2, C5, C6, C7, C8, C9 — 0.1  $\mu\text{F}$  Ceramic Chip or Monolithic with Short Leads
- C3 — Arco 469
- C4 — 560 pF Unencapsulated Mica or Dipped Mica with Short Leads
- C10 — 10  $\mu\text{F}/100 \text{ V}$  Electrolytic

- L1 — VK200/4B Ferrite Choke or Equivalent, 3.0  $\mu\text{H}$
- L2 — Ferrite Bead(s), 2.0  $\mu\text{H}$
- R1, R2 — 51  $\Omega/1.0 \text{ W}$  Carbon
- R3 — 1.0  $\Omega/1.0 \text{ W}$  Carbon
- T1 — 16:1 Broadband Transformer
- T2 — 1:25 Broadband Transformer
- Board Material — 0.062" Fiberglass (G10), 1 oz. Copper Clad, 2 Sides,  $\epsilon_r = 5$

**Figure 1. 30 MHz Test Circuit**

## TYPICAL CHARACTERISTICS

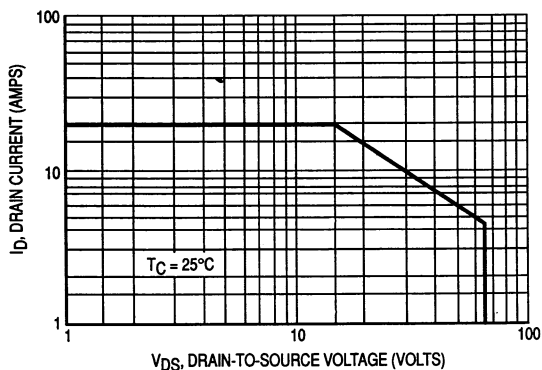


Figure 2. DC Safe Operating Area

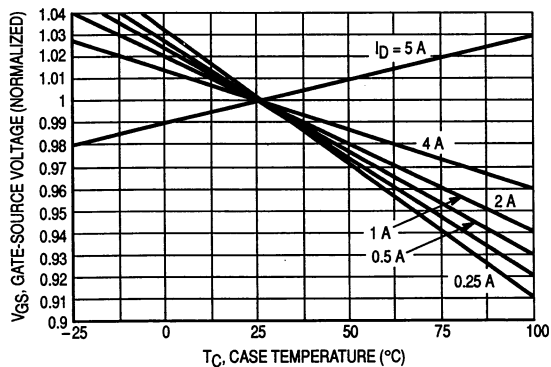


Figure 3. Gate-Source Voltage versus Case Temperature

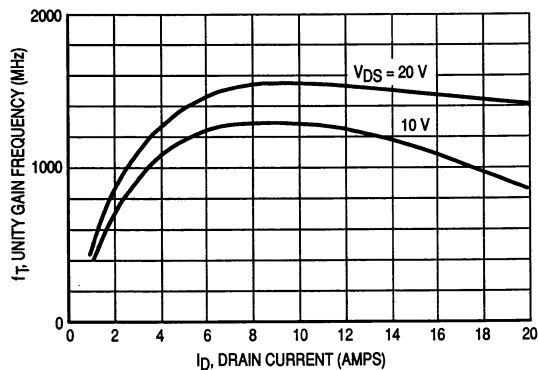


Figure 4. Common Source Unity Gain Frequency versus Drain Current

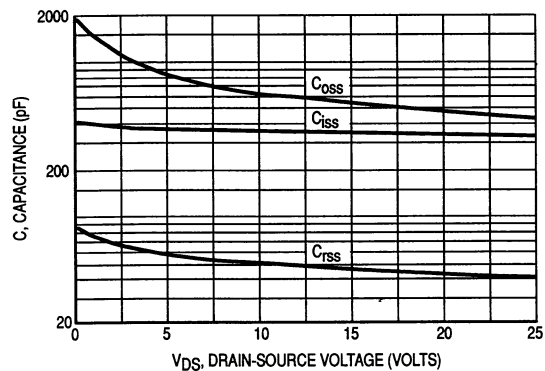


Figure 5. Capacitance versus Drain-Source Voltage

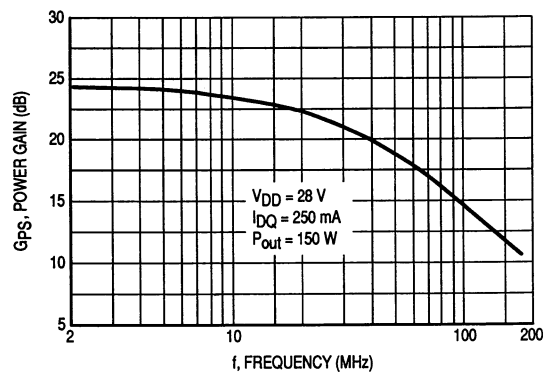


Figure 6. Power Gain versus Frequency

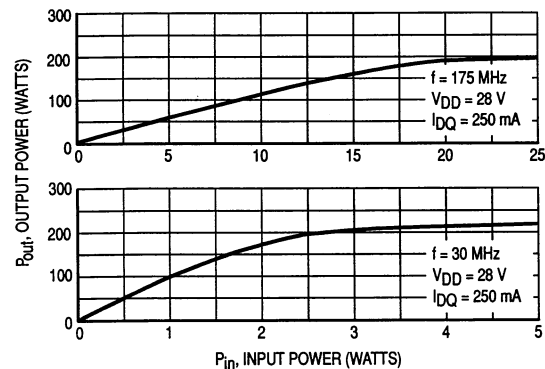


Figure 7. Output Power versus Input Power

## TYPICAL CHARACTERISTICS

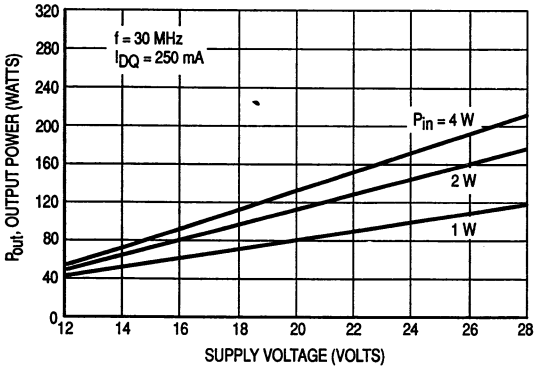


Figure 8. Output Power versus Supply Voltage

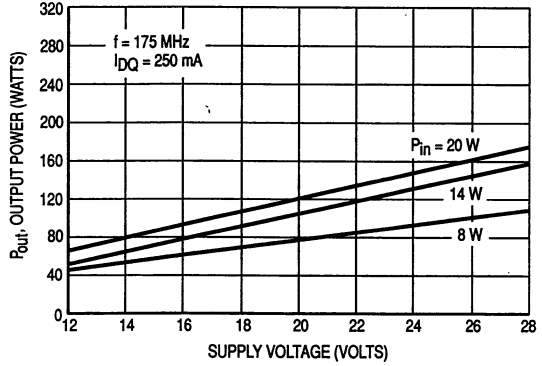


Figure 9. Output Power versus Supply Voltage

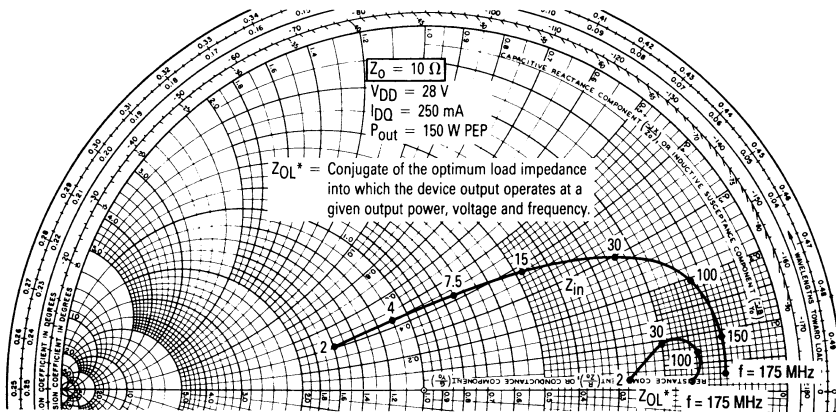


Figure 10. Input and Output Impedances

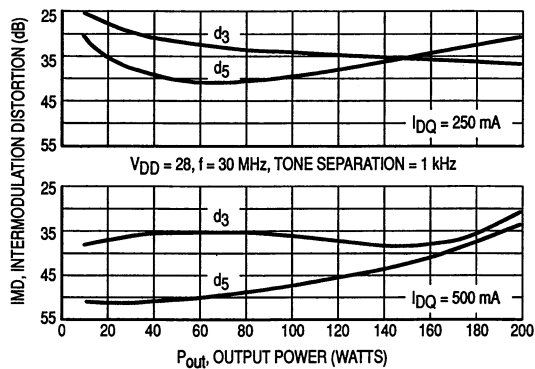


Figure 11. IMD versus  $P_{out}$  (PEP)

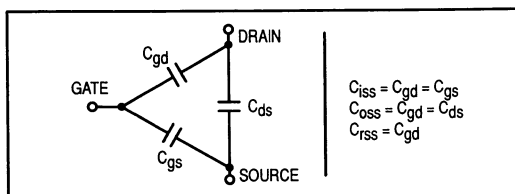
## RF POWER MOSFET CONSIDERATIONS

### MOSFET CAPACITANCES

The physical structure of a MOSFET results in capacitors between the terminals. The metal anode gate structure determines the capacitances from gate-to-drain ( $C_{gd}$ ), and gate-to-source ( $C_{gs}$ ). The PN junction formed during the fabrication of the MOSFET results in a junction capacitance from drain-to-source ( $C_{ds}$ ).

These capacitances are characterized as input ( $C_{iss}$ ), output ( $C_{oss}$ ) and reverse transfer ( $C_{rss}$ ) capacitances on data sheets. The relationships between the inter-terminal capacitances and those given on data sheets are shown below. The  $C_{iss}$  can be specified in two ways:

1. Drain shorted to source and positive voltage at the gate.
2. Positive voltage of the drain in respect to source and zero volts at the gate. In the latter case the numbers are lower. However, neither method represents the actual operating conditions in RF applications.



### LINEARITY AND GAIN CHARACTERISTICS

In addition to the typical IMD and power gain data presented, Figure 4 may give the designer additional information on the capabilities of this device. The graph represents the small signal unity current gain frequency at a given drain current level. This is equivalent to  $f_T$  for bipolar transistors. Since this test is performed at a fast sweep speed, heating of the device does not occur. Thus, in normal use, the higher temperatures may degrade these characteristics to some extent.

### DRAIN CHARACTERISTICS

One figure of merit for a FET is its static resistance in the full-on condition. This on-resistance,  $V_{DS(on)}$ , occurs in the linear region of the output characteristic and is specified under specific test conditions for gate-source voltage and drain current. For MOSFETs,  $V_{DS(on)}$  has a positive temperature coefficient and constitutes an important design consideration at high temperatures, because it contributes to the power dissipation within the device.

### GATE CHARACTERISTICS

The gate of the MOSFET is a polysilicon material, and is electrically isolated from the source by a layer of oxide. The input resistance is very high — on the order of  $10^9$  ohms — resulting in a leakage current of a few nanoamperes.

Gate control is achieved by applying a positive voltage slightly in excess of the gate-to-source threshold voltage,  $V_{GS(th)}$ .

**Gate Voltage Rating** — Never exceed the gate voltage rating. Exceeding the rated  $V_{GS}$  can result in permanent damage to the oxide layer in the gate region.

**Gate Termination** — The gate of this device is essentially capacitor. Circuits that leave the gate open-circuited or float-

ing should be avoided. These conditions can result in turn-on of the device due to voltage build-up on the input capacitor due to leakage currents or pickup.

**Gate Protection** — This device does not have an internal monolithic zener diode from gate-to-source. If gate protection is required, an external zener diode is recommended.

Using a resistor to keep the gate-to-source impedance low also helps damp transients and serves another important function. Voltage transients on the drain can be coupled to the gate through the parasitic gate-drain capacitance. If the gate-to-source impedance and the rate of voltage change on the drain are both high, then the signal coupled to the gate may be large enough to exceed the gate-threshold voltage and turn the device on.

### HANDLING CONSIDERATIONS

When shipping, the devices should be transported only in antistatic bags or conductive foam. Upon removal from the packaging, careful handling procedures should be adhered to. Those handling the devices should wear grounding straps and devices not in the antistatic packaging should be kept in metal tote bins. MOSFETs should be handled by the case and not by the leads, and when testing the device, all leads should make good electrical contact before voltage is applied. As a final note, when placing the FET into the system it is designed for, soldering should be done with a grounded iron.

### DESIGN CONSIDERATIONS

The MRF141 is an RF Power, MOS, N-channel enhancement mode field-effect transistor (FET) designed for HF and VHF power amplifier applications.

Motorola Application Note AN211A, FETs in Theory and Practice, is suggested reading for those not familiar with the construction and characteristics of FETs.

The major advantages of RF power MOSFETs include high gain, low noise, simple bias systems, relative immunity from thermal runaway, and the ability to withstand severely mismatched loads without suffering damage. Power output can be varied over a wide range with a low power dc control signal.

### DC BIAS

The MRF141 is an enhancement mode FET and, therefore, does not conduct when drain voltage is applied. Drain current flows when a positive voltage is applied to the gate. RF power FETs require forward bias for optimum performance. The value of quiescent drain current ( $I_{DQ}$ ) is not critical for many applications. The MRF141 was characterized at  $I_{DQ} = 250$  mA, each side, which is the suggested minimum value of  $I_{DQ}$ . For special applications such as linear amplification,  $I_{DQ}$  may have to be selected to optimize the critical parameters.

The gate is a dc open circuit and draws no current. Therefore, the gate bias circuit may be just a simple resistive divider network. Some applications may require a more elaborate bias system.

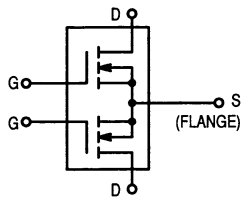
### GAIN CONTROL

Power output of the MRF141 may be controlled from its rated value down to zero (negative gain) by varying the dc gate voltage. This feature facilitates the design of manual gain control, AGC/ALC and modulation systems.

The RF MOSFET Line  
**RF Power Field-Effect Transistor**  
**N-Channel Enhancement-Mode MOSFET**

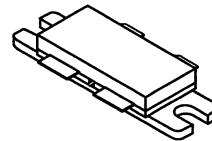
... designed for broadband commercial and military applications at frequencies to 175 MHz. The high power, high gain and broadband performance of this device makes possible solid state transmitters for FM broadcast or TV channel frequency bands.

- Guaranteed Performance at 175 MHz, 28 V:  
 Output Power — 300 W  
 Gain — 12 dB (14 dB Typ)  
 Efficiency — 50%
- Low Thermal Resistance — 0.35°C/W
- Ruggedness Tested at Rated Output Power
- Nitride Passivated Die for Enhanced Reliability



**MRF141G**

**300 W, 28 V, 175 MHz**  
**N-CHANNEL**  
**BROADBAND**  
**RF POWER MOSFET**



**CASE 375, STYLE 2**

**MAXIMUM RATINGS**

Rating	Symbol	Value	Unit
Drain-Source Voltage	V <sub>DSS</sub>	65	Vdc
Drain-Gate Voltage	V <sub>DGO</sub>	65	Vdc
Gate-Source Voltage	V <sub>GS</sub>	±40	Vdc
Drain Current — Continuous	I <sub>D</sub>	32	Adc
Total Device Dissipation @ T <sub>C</sub> = 25°C Derate above 25°C	P <sub>D</sub>	500 2.85	Watts W/°C
Storage Temperature Range	T <sub>stg</sub>	-65 to +150	°C
Operating Junction Temperature	T <sub>J</sub>	200	°C

**THERMAL CHARACTERISTICS**

Characteristic	Symbol	Max	Unit
Thermal Resistance, Junction to Case	R <sub>θJC</sub>	0.35	°C/W

**NOTE — CAUTION** — MOS devices are susceptible to damage from electrostatic charge. Reasonable precautions in handling and packaging MOS devices should be observed.

**ELECTRICAL CHARACTERISTICS** ( $T_C = 25^\circ\text{C}$  unless otherwise noted.)

Characteristic	Symbol	Min	Typ	Max	Unit
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**OFF CHARACTERISTICS (1)**

Drain-Source Breakdown Voltage ( $V_{GS} = 0, I_D = 100\text{ mA}$ )	$V_{(BR)DSS}$	65	—	—	Vdc
Zero Gate Voltage Drain Current ( $V_{DS} = 28\text{ V}, V_{GS} = 0$ )	$I_{DSS}$	—	—	5.0	mAdc
Gate-Body Leakage Current ( $V_{GS} = 20\text{ V}, V_{DS} = 0$ )	$I_{GSS}$	—	—	1.0	$\mu\text{Adc}$

**ON CHARACTERISTICS (1)**

Gate Threshold Voltage ( $V_{DS} = 10\text{ V}, I_D = 100\text{ mA}$ )	$V_{GS(th)}$	1.0	3.0	5.0	Vdc
Drain-Source On-Voltage ( $V_{GS} = 10\text{ V}, I_D = 10\text{ A}$ )	$V_{DS(on)}$	—	—	1.5	Vdc
Forward Transconductance ( $V_{DS} = 10\text{ V}, I_D = 5.0\text{ A}$ )	$g_{fs}$	5.0	7.0	—	mhos

**DYNAMIC CHARACTERISTICS (1)**

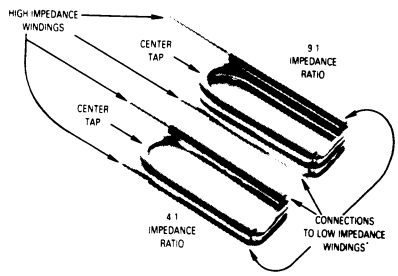
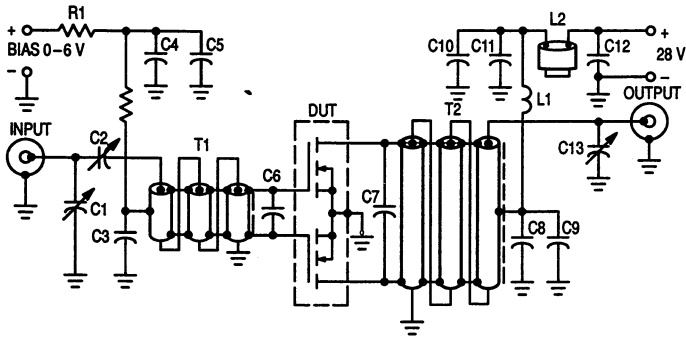
Input Capacitance ( $V_{DS} = 28\text{ V}, V_{GS} = 0, f = 1.0\text{ MHz}$ )	$C_{iss}$	—	350	—	pF
Output Capacitance ( $V_{DS} = 28\text{ V}, V_{GS} = 0, f = 1.0\text{ MHz}$ )	$C_{oss}$	—	420	—	pF
Reverse Transfer Capacitance ( $V_{DS} = 28\text{ V}, V_{GS} = 0, f = 1.0\text{ MHz}$ )	$C_{rss}$	—	40	—	pF

**FUNCTIONAL TESTS (2)**

Common Source Amplifier Power Gain ( $V_{DD} = 28\text{ V}, P_{out} = 300\text{ W}, I_{DQ} = 500\text{ mA}, f = 175\text{ MHz}$ )	$G_{ps}$	12	14	—	dB
Drain Efficiency ( $V_{DD} = 28\text{ V}, P_{out} = 300\text{ W}, f = 175\text{ MHz}, I_D(\text{Max}) = 21.4\text{ A}$ )	$\eta$	45	55	—	%
Load Mismatch ( $V_{DD} = 28\text{ V}, P_{out} = 300\text{ W}, I_{DQ} = 500\text{ mA}, f = 175\text{ MHz},$ VSWR 5:1 at all Phase Angles)	$\psi$	No Degradation in Output Power			

## NOTES:

- Each side measured separately.
- Measured in push-pull configuration.



- C1 — Arco 402, 1.5–20 pF
- C2 — Arco 406, 15–115 pF
- C3, C4, C8, C9, C10 — 1000 pF Chip
- C5, C11 — 0.1  $\mu$ F Chip
- C6 — 330 pF Chip
- C7 — 200 pF and 180 pF Chips in Parallel
- C12 — 0.47  $\mu$ F Ceramic Chip, Kemet 1215 or Equivalent
- C13 — Arco 403, 3.0–35 pF
- L1 — 10 Turns AWG #16 Enameled Wire, Close Wound, 1/4" I.D.
- L2 — Ferrite Beads of Suitable Material for 1.5–2.0  $\mu$ H Total Inductance
- R1 — 100 Ohms, 1/2 W
- R2 — 1.0 kOhm, 1/2 W

- T1 — 9:1 RF Transformer. Can be made of 15–18 Ohms Semirigid Co-Ax, 62–90 Mils O.D.
- T2 — 1:9 RF Transformer. Can be made of 15–18 Ohms Semirigid Co-Ax, 70–90 Mils O.D.

Board Material — 0.062" Fiberglass (G10), 1 oz. Copper Clad, 2 Sides,  $\epsilon_r = 5$

NOTE: For stability, the input transformer T1 must be loaded with ferrite toroids or beads to increase the common mode inductance. For operation below 100 MHz. The same is required for the output transformer.

See pictures for construction details.

Unless Otherwise Noted, All Chip Capacitors are ATC Type 100 or Equivalent.

Figure 1. 175 MHz Test Circuit

### TYPICAL CHARACTERISTICS

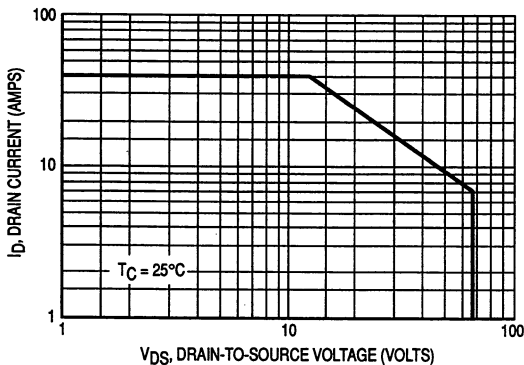


Figure 2. DC Safe Operating Area

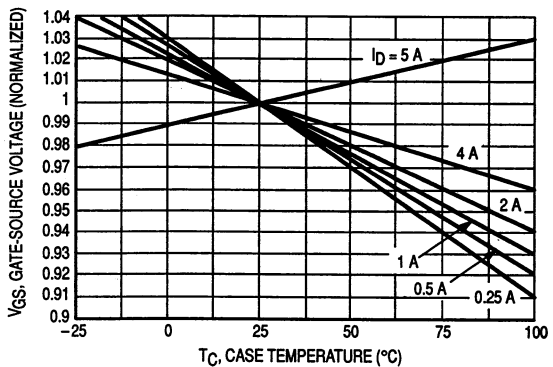
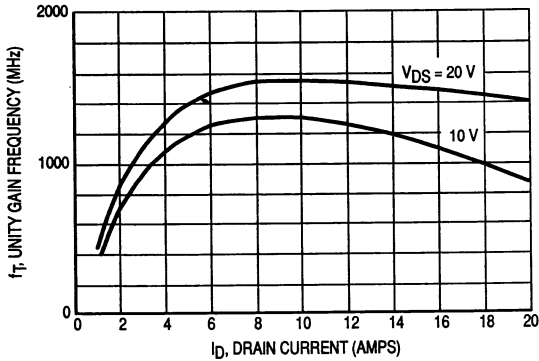


Figure 3. Gate-Source Voltage versus Case Temperature

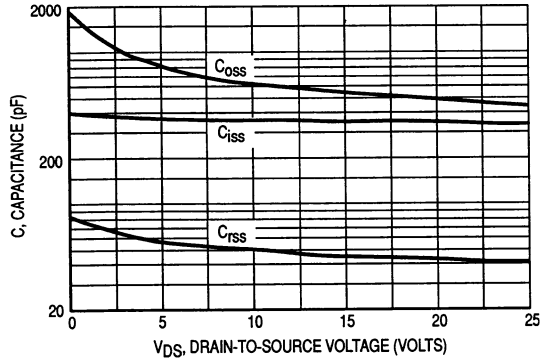


## TYPICAL CHARACTERISTICS



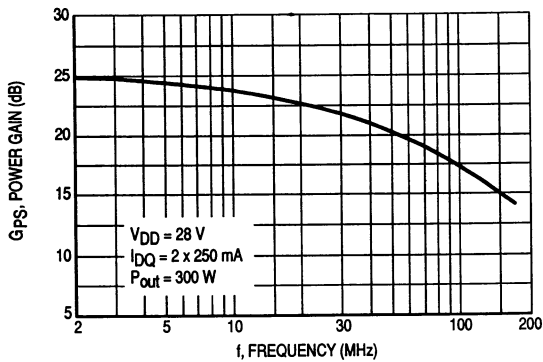
NOTE: Data shown applies to each half of MRF141G.

**Figure 4. Common Source Unity Gain Frequency versus Drain Current**

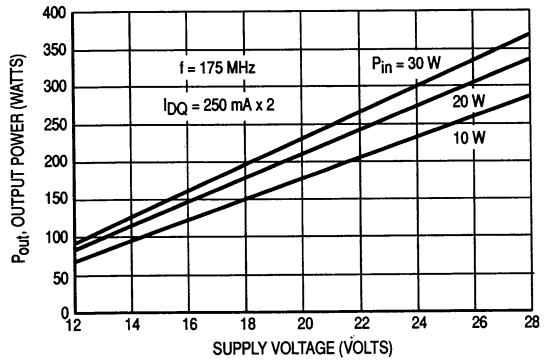


NOTE: Data shown applies to each half of MRF141G.

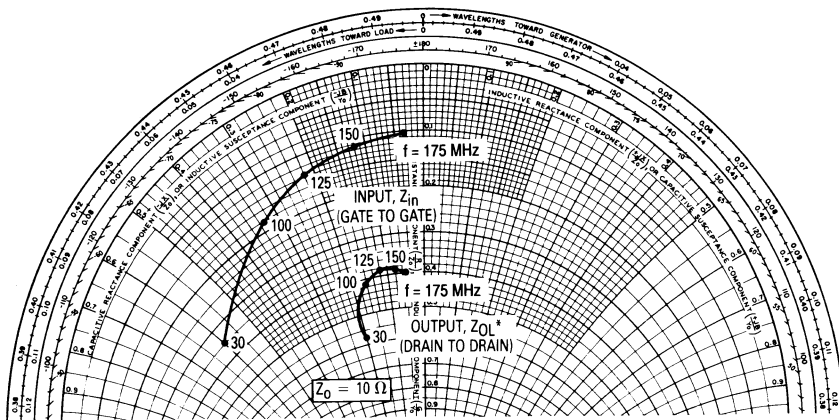
**Figure 5. Capacitance versus Drain-Source Voltage**



**Figure 6. Power Gain versus Frequency**



**Figure 7. Output Power versus Supply Voltage**



$Z_{OL}^*$  = Conjugate of the optimum load impedance into which the device output operates at a given output power, voltage and frequency.

**Figure 8. Input and Output Impedances**

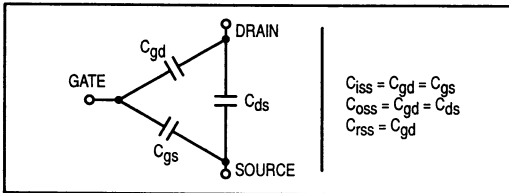
## RF POWER MOSFET CONSIDERATIONS

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### LINEARITY AND GAIN CHARACTERISTICS

In addition to the typical IMD and power gain data presented, Figure 4 may give the designer additional information on the capabilities of this device. The graph represents the small signal unity current gain frequency at a given drain current level. This is equivalent to  $f_T$  for bipolar transistors. Since this test is performed at a fast sweep speed, heating of the device does not occur. Thus, in normal use, the higher temperatures may degrade these characteristics to some extent.

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The gate of the MOSFET is a polysilicon material, and is electrically isolated from the source by a layer of oxide. The input resistance is very high — on the order of  $10^9$  ohms — resulting in a leakage current of a few nanoamperes.

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**Gate Voltage Rating** — Never exceed the gate voltage rating. Exceeding the rated  $V_{GS}$  can result in permanent damage to the oxide layer in the gate region.

**Gate Termination** — The gate of this device is essentially capacitor. Circuits that leave the gate open-circuited or float-

ing should be avoided. These conditions can result in turn-on of the device due to voltage build-up on the input capacitor due to leakage currents or pickup.

**Gate Protection** — This device does not have an internal monolithic zener diode from gate-to-source. If gate protection is required, an external zener diode is recommended.

Using a resistor to keep the gate-to-source impedance low also helps damp transients and serves another important function. Voltage transients on the drain can be coupled to the gate through the parasitic gate-drain capacitance. If the gate-to-source impedance and the rate of voltage change on the drain are both high, then the signal coupled to the gate may be large enough to exceed the gate-threshold voltage and turn the device on.

### HANDLING CONSIDERATIONS

When shipping, the devices should be transported only in antistatic bags or conductive foam. Upon removal from the packaging, careful handling procedures should be adhered to. Those handling the devices should wear grounding straps and devices not in the antistatic packaging should be kept in metal tote bins. MOSFETs should be handled by the case and not by the leads, and when testing the device, all leads should make good electrical contact before voltage is applied. As a final note, when placing the FET into the system it is designed for, soldering should be done with a grounded iron.

### DESIGN CONSIDERATIONS

The MRF141G is an RF Power, MOS, N-channel enhancement mode field-effect transistor (FET) designed for HF and VHF power amplifier applications.

Motorola Application Note AN211A, FETs in Theory and Practice, is suggested reading for those not familiar with the construction and characteristics of FETs.

The major advantages of RF power MOSFETs include high gain, low noise, simple bias systems, relative immunity from thermal runaway, and the ability to withstand severely mismatched loads without suffering damage. Power output can be varied over a wide range with a low power dc control signal.

### DC BIAS

The MRF141G is an enhancement mode FET and, therefore, does not conduct when drain voltage is applied. Drain current flows when a positive voltage is applied to the gate. RF power FETs require forward bias for optimum performance. The value of quiescent drain current ( $I_{DQ}$ ) is not critical for many applications. The MRF141G was characterized at  $I_{DQ} = 250$  mA, each side, which is the suggested minimum value of  $I_{DQ}$ . For special applications such as linear amplification,  $I_{DQ}$  may have to be selected to optimize the critical parameters.

The gate is a dc open circuit and draws no current. Therefore, the gate bias circuit may be just a simple resistive divider network. Some applications may require a more elaborate bias system.

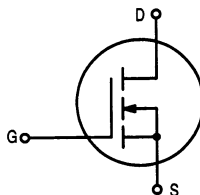
### GAIN CONTROL

Power output of the MRF141G may be controlled from its rated value down to zero (negative gain) by varying the dc gate voltage. This feature facilitates the design of manual gain control, AGC/ALC and modulation systems.

The RF MOSFET Line  
**RF Power Field-Effect Transistor**  
**N-Channel Enhancement-Mode MOSFET**

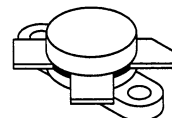
... designed for broadband commercial and military applications at frequencies to 175 MHz. The high power, high gain and broadband performance of this device makes possible solid state transmitters for FM broadcast or TV channel frequency bands.

- Guaranteed Performance at 30 MHz, 50 V:  
 Output Power — 150 W  
 Gain — 18 dB (22 dB Typ)  
 Efficiency — 40%
- Typical Performance at 175 MHz, 50 V:  
 Output Power — 150 W  
 Gain — 13 dB
- Low Thermal Resistance
- Ruggedness Tested at Rated Output Power
- Nitride Passivated Die for Enhanced Reliability



**MRF151**

**150 W, 50 V, 175 MHz**  
**N-CHANNEL**  
**BROADBAND**  
**RF POWER MOSFET**



**CASE 211-11, STYLE 2**

**MAXIMUM RATINGS**

Rating	Symbol	Value	Unit
Drain-Source Voltage	$V_{DSS}$	125	Vdc
Drain-Gate Voltage	$V_{DGO}$	125	Vdc
Gate-Source Voltage	$V_{GS}$	$\pm 40$	Vdc
Drain Current — Continuous	$I_D$	16	Adc
Total Device Dissipation @ $T_C = 25^\circ\text{C}$ Derate above $25^\circ\text{C}$	$P_D$	300 1.71	Watts W/ $^\circ\text{C}$
Storage Temperature Range	$T_{stg}$	-65 to +150	$^\circ\text{C}$
Operating Junction Temperature	$T_J$	200	$^\circ\text{C}$

**THERMAL CHARACTERISTICS**

Characteristic	Symbol	Max	Unit
Thermal Resistance, Junction to Case	$R_{\theta JC}$	0.6	$^\circ\text{C/W}$

**NOTE — CAUTION** — MOS devices are susceptible to damage from electrostatic charge. Reasonable precautions in handling and packaging MOS devices should be observed.

**ELECTRICAL CHARACTERISTICS** ( $T_C = 25^\circ\text{C}$  unless otherwise noted.)

Characteristic	Symbol	Min	Typ	Max	Unit
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**OFF CHARACTERISTICS**

Drain-Source Breakdown Voltage ( $V_{GS} = 0, I_D = 100 \text{ mA}$ )	$V_{(BR)DSS}$	125	—	—	Vdc
Zero Gate Voltage Drain Current ( $V_{DS} = 50 \text{ V}, V_{GS} = 0$ )	$I_{DSS}$	—	—	5.0	mAdc
Gate-Body Leakage Current ( $V_{GS} = 20 \text{ V}, V_{DS} = 0$ )	$I_{GSS}$	—	—	1.0	$\mu\text{Adc}$

**ON CHARACTERISTICS**

Gate Threshold Voltage ( $V_{DS} = 10 \text{ V}, I_D = 100 \text{ mA}$ )	$V_{GS(th)}$	1.0	3.0	5.0	Vdc
Drain-Source On-Voltage ( $V_{GS} = 10 \text{ V}, I_D = 10 \text{ A}$ )	$V_{DS(on)}$	—	—	5.0	Vdc
Forward Transconductance ( $V_{DS} = 10 \text{ V}, I_D = 5.0 \text{ A}$ )	$g_{fs}$	5.0	7.0	—	mhos

**DYNAMIC CHARACTERISTICS**

Input Capacitance ( $V_{DS} = 50 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{iss}$	—	350	—	pF
Output Capacitance ( $V_{DS} = 50 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{oss}$	—	225	—	pF
Reverse Transfer Capacitance ( $V_{DS} = 50 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{rss}$	—	20	—	pF

**FUNCTIONAL TESTS**

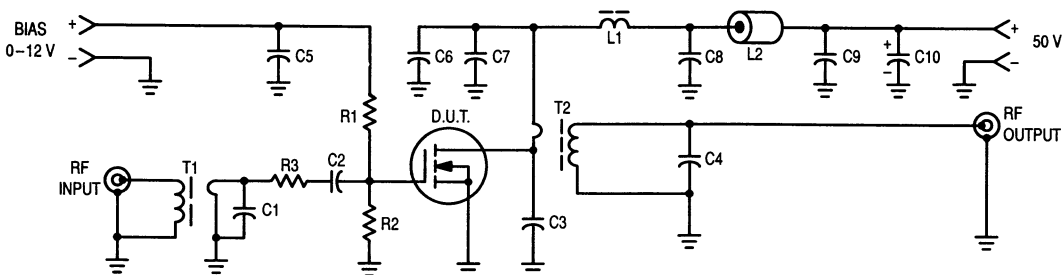
Common Source Amplifier Power Gain, $f = 30; 30.001 \text{ MHz}$ ( $V_{DD} = 50 \text{ V}, P_{out} = 150 \text{ W (PEP)}, I_{DQ} = 250 \text{ mA}, f = 175 \text{ MHz}$ )	$G_{ps}$	18 —	22 13	— —	dB
Drain Efficiency ( $V_{DD} = 50 \text{ V}, P_{out} = 150 \text{ W (PEP)}, f = 30; 30.001 \text{ MHz}, I_D (\text{Max}) = 3.75 \text{ A}$ )	$\eta$	40	45	—	%
Intermodulation Distortion (1) ( $V_{DD} = 50 \text{ V}, P_{out} = 150 \text{ W (PEP)}, f = 30 \text{ MHz}, f_2 = 30.001 \text{ MHz}, I_{DQ} = 250 \text{ mA}$ )	IMD(d3) IMD(d11)	— —	-32 -60	-30 —	dB
Load Mismatch ( $V_{DD} = 50 \text{ V}, P_{out} = 150 \text{ W (PEP)}, f_1 = 30; 30.001 \text{ MHz}, I_{DQ} = 250 \text{ mA}, \text{VSWR } 30:1 \text{ at all Phase Angles}$ )	$\psi$	No Degradation in Output Power			

**CLASS A PERFORMANCE**

Intermodulation Distortion (1) and Power Gain ( $V_{DD} = 50 \text{ V}, P_{out} = 50 \text{ W (PEP)}, f_1 = 30 \text{ MHz}, f_2 = 30.001 \text{ MHz}, I_{DQ} = 3.0 \text{ A}$ )	$G_{PS}$ IMD(d3) IMD(d9-13)	— — —	23 -50 -75	— — —	dB
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NOTE:

- To MIL-STD-1311 Version A, Test Method 2204B, Two Tone, Reference Each Tone.



C1 — 470 pF Dipped Mica

C2, C5, C6, C7, C8, C9 — 0.1  $\mu\text{F}$  Ceramic Chip or Monolithic with Short Leads

C3 — 200 pF Unencapsulated Mica or Dipped Mica with Short Leads

C4 — 15 pF Unencapsulated Mica or Dipped Mica with Short Leads

C10 — 10  $\mu\text{F}/100 \text{ V}$  Electrolytic

L1 — VK200/4B Ferrite Choke or Equivalent, 3.0  $\mu\text{H}$

L2 — Ferrite Bead(s), 2.0  $\mu\text{H}$

R1, R2 — 51  $\Omega/1.0 \text{ W}$  Carbon

R3 — 3.3  $\Omega/1.0 \text{ W}$  Carbon (or 2.0 x 6.8  $\Omega/1/2 \text{ W}$  in Parallel)

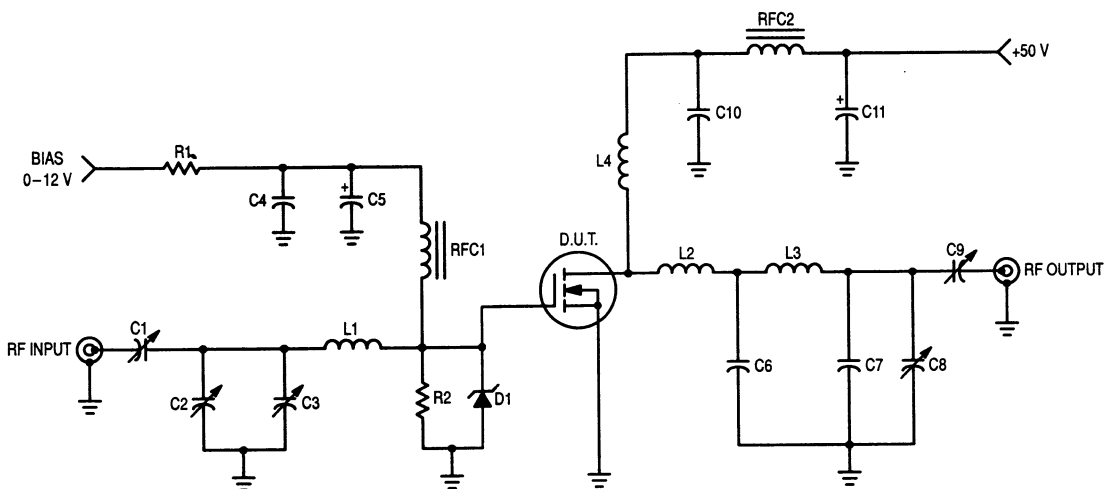
T1 — 9:1 Broadband Transformer

T2 — 1:9 Broadband Transformer

Board Material — 0.062" Fiberglass (G10),

1 oz. Copper Clad, 2 Sides,  $\epsilon_r = 5$

Figure 1. 30 MHz Test Circuit



C1, C2, C8 — Arco 463 or equivalent  
 C3 — 25 pF Unelco  
 C4 — 0.1  $\mu$ F Ceramic  
 C5 — 1.0  $\mu$ F, 15 WV Tantalum  
 C6 — 250 pF Unelco J101  
 C7 — 25  $\mu$ F Unelco J101  
 C9 — Arco 262 or equivalent  
 C10 — 0.05  $\mu$ F Ceramic  
 C11 — 15  $\mu$ F, 60 WV Electrolytic

D1 — 1N5347 Zener Diode  
 L1 — 3/4" #18 AWG into Hairpin  
 L2 — Printed Line, 0.200" x 0.500"  
 L3 — 1" #16 AWG into Hairpin  
 L4 — 2 Turns #16 AWG, 5/16 ID  
 RFC1 — 5.6  $\mu$ H Choke  
 RFC2 — VK200-4B  
 R1, R2 — 150  $\Omega$ , 1.0 W Carbon  
 Board Material — 0.062" Fiberglass (G10),  
 1 oz. Copper Clad, 2 Sides,  $\epsilon_r = 5.0$

Figure 2. 175 MHz Test Circuit

### TYPICAL CHARACTERISTICS

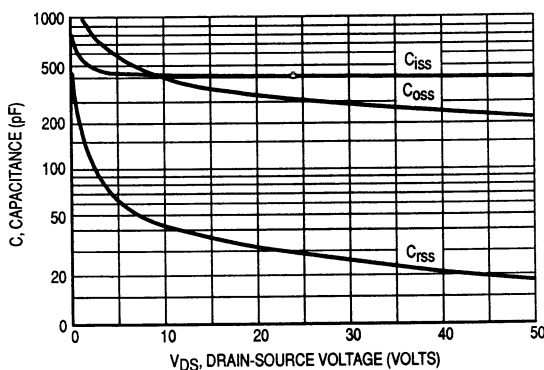


Figure 3. Capacitance versus Drain-Source Voltage

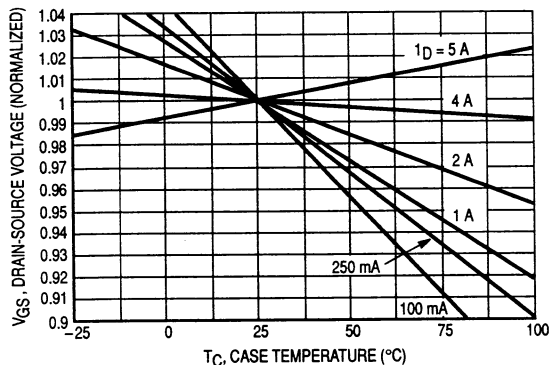


Figure 4. Gate-Source Voltage versus Case Temperature

## TYPICAL CHARACTERISTICS

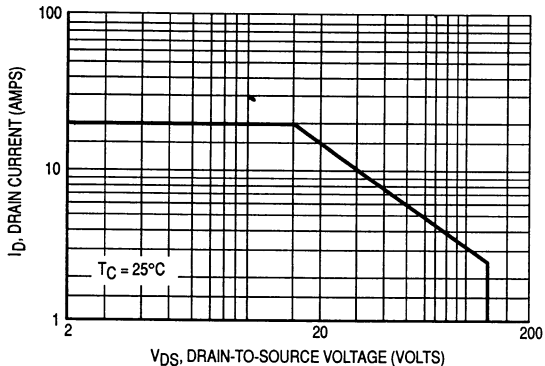


Figure 5. DC Safe Operating Area

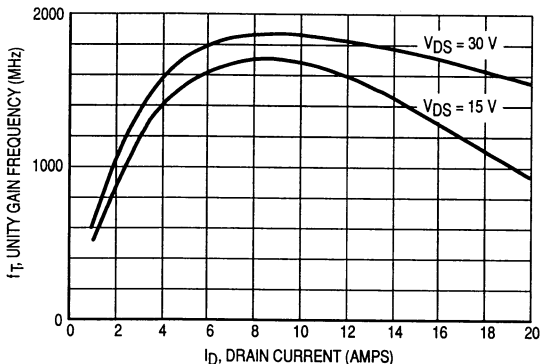


Figure 6. Common Source Unity Gain Frequency versus Drain Current

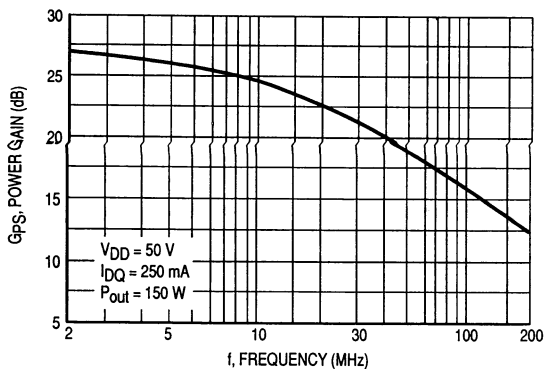


Figure 7. Power Gain versus Frequency

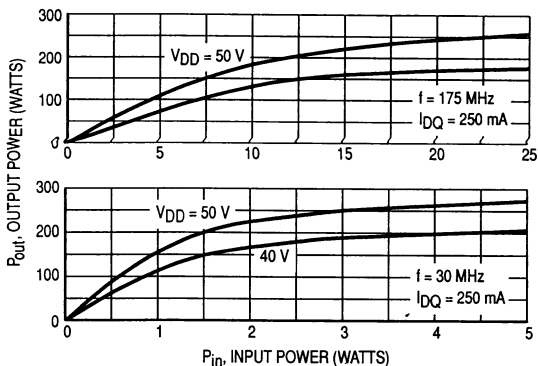


Figure 8. Output Power versus Input Power

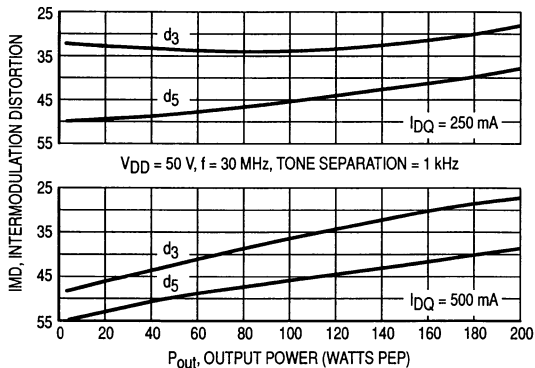


Figure 9. IMD versus  $P_{out}$

2

## TYPICAL CHARACTERISTICS

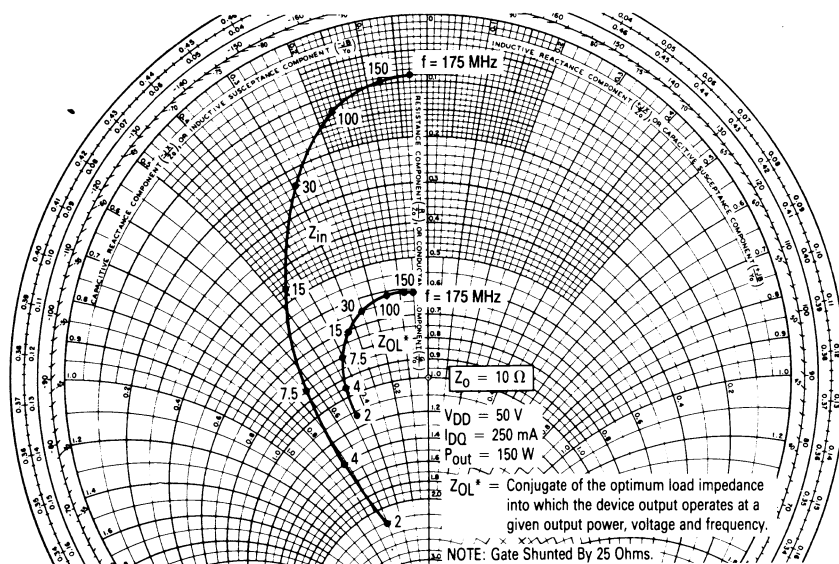


Figure 10. Series Equivalent Impedance

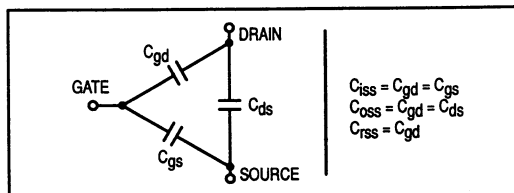
## RF POWER MOSFET CONSIDERATIONS

### MOSFET CAPACITANCES

The physical structure of a MOSFET results in capacitors between the terminals. The metal anode gate structure determines the capacitors from gate-to-drain ( $C_{gd}$ ), and gate-to-source ( $C_{gs}$ ). The PN junction formed during the fabrication of the MOSFET results in a junction capacitance from drain-to-source ( $C_{ds}$ ).

These capacitances are characterized as input ( $C_{iss}$ ), output ( $C_{oss}$ ) and reverse transfer ( $C_{rss}$ ) capacitances on data sheets. The relationships between the inter-terminal capacitances and those given on data sheets are shown below. The  $C_{iss}$  can be specified in two ways:

1. Drain shorted to source and positive voltage at the gate.
2. Positive voltage of the drain in respect to source and zero volts at the gate. In the latter case the numbers are lower. However, neither method represents the actual operating conditions in RF applications.



### LINEARITY AND GAIN CHARACTERISTICS

In addition to the typical IMD and power gain data presented, Figure 6 may give the designer additional information on the capabilities of this device. The graph represents the small signal unity current gain frequency at a given drain cur-

rent level. This is equivalent to  $f_T$  for bipolar transistors. Since this test is performed at a fast sweep speed, heating of the device does not occur. Thus, in normal use, the higher temperatures may degrade these characteristics to some extent.

### DRAIN CHARACTERISTICS

One figure of merit for a FET is its static resistance in the full-on condition. This on-resistance,  $V_{DS(on)}$ , occurs in the linear region of the output characteristic and is specified under specific test conditions for gate-source voltage and drain current. For MOSFETs,  $V_{DS(on)}$  has a positive temperature coefficient and constitutes an important design consideration at high temperatures, because it contributes to the power dissipation within the device.

### GATE CHARACTERISTICS

The gate of the MOSFET is a polysilicon material, and is electrically isolated from the source by a layer of oxide. The input resistance is very high — on the order of  $10^9$  ohms — resulting in a leakage current of a few nanoamperes.

Gate control is achieved by applying a positive voltage slightly in excess of the gate-to-source threshold voltage,  $V_{GS(th)}$ .

**Gate Voltage Rating** — Never exceed the gate voltage rating. Exceeding the rated  $V_{GS}$  can result in permanent damage to the oxide layer in the gate region.

**Gate Termination** — The gate of this device is essentially a capacitor. Circuits that leave the gate open-circuited or floating should be avoided. These conditions can result in turn-on of the device due to voltage build-up on the input capacitor due to leakage currents or pickup.

**Gate Protection** — This device does not have an internal monolithic zener diode from gate-to-source. If gate protection is required, an external zener diode is recommended.

Using a resistor to keep the gate-to-source impedance low also helps damp transients and serves another important function. Voltage transients on the drain can be coupled to the gate through the parasitic gate-drain capacitance. If the gate-to-source impedance and the rate of voltage change on the drain are both high, then the signal coupled to the gate may be large enough to exceed the gate-threshold voltage and turn the device on.

#### **HANDLING CONSIDERATIONS**

When shipping, the devices should be transported only in antistatic bags or conductive foam. Upon removal from the packaging, careful handling procedures should be adhered to. Those handling the devices should wear grounding straps and devices not in the antistatic packaging should be kept in metal tote bins. MOSFETs should be handled by the case and not by the leads, and when testing the device, all leads should make good electrical contact before voltage is applied. As a final note, when placing the FET into the system it is designed for, soldering should be done with a grounded iron.

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#### **DC BIAS**

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#### **GAIN CONTROL**

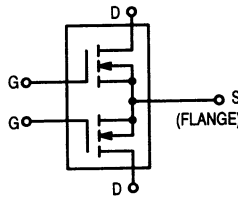
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**RF Power Field-Effect Transistor**  
**N-Channel Enhancement-Mode MOSFET**

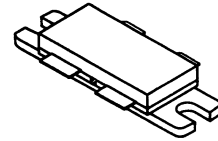
... designed for broadband commercial and military applications at frequencies to 175 MHz. The high power, high gain and broadband performance of this device makes possible solid state transmitters for FM broadcast or TV channel frequency bands.

- Guaranteed Performance at 175 MHz, 50 V:  
 Output Power — 300 W  
 Gain — 14 dB (16 dB Typ)  
 Efficiency — 50%
- Low Thermal Resistance — 0.35°C/W
- Ruggedness Tested at Rated Output Power
- Nitride Passivated Die for Enhanced Reliability



**MRF151G**

**300 W, 50 V, 175 MHz**  
**N-CHANNEL**  
**BROADBAND**  
**RF POWER MOSFET**



**CASE 375, STYLE 2**

**MAXIMUM RATINGS**

Rating	Symbol	Value	Unit
Drain-Source Voltage	$V_{DSS}$	125	Vdc
Drain-Gate Voltage	$V_{DGO}$	125	Vdc
Gate-Source Voltage	$V_{GS}$	$\pm 40$	Vdc
Drain Current — Continuous	$I_D$	40	Adc
Total Device Dissipation @ $T_C = 25^\circ\text{C}$ Derate above 25°C	$P_D$	500 2.85	Watts W/°C
Storage Temperature Range	$T_{stg}$	-65 to +150	°C
Operating Junction Temperature	$T_J$	200	°C

**THERMAL CHARACTERISTICS**

Characteristic	Symbol	Max	Unit
Thermal Resistance, Junction to Case	$R_{\theta JC}$	0.35	°C/W

**NOTE — CAUTION —** MOS devices are susceptible to damage from electrostatic charge. Reasonable precautions in handling and packaging MOS devices should be observed.

**ELECTRICAL CHARACTERISTICS** ( $T_C = 25^\circ\text{C}$  unless otherwise noted.)

Characteristic	Symbol	Min	Typ	Max	Unit
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**OFF CHARACTERISTICS (Each Side)**

Drain-Source Breakdown Voltage ( $V_{GS} = 0, I_D = 100 \text{ mA}$ )	$V_{(BR)DSS}$	125	—	—	Vdc
Zero Gate Voltage Drain Current ( $V_{DS} = 50 \text{ V}, V_{GS} = 0$ )	$I_{DSS}$	—	—	5.0	mAdc
Gate-Body Leakage Current ( $V_{GS} = 20 \text{ V}, V_{DS} = 0$ )	$I_{GSS}$	—	—	1.0	$\mu\text{Adc}$

**ON CHARACTERISTICS (Each Side)**

Gate Threshold Voltage ( $V_{DS} = 10 \text{ V}, I_D = 100 \text{ mA}$ )	$V_{GS(th)}$	1.0	3.0	5.0	Vdc
Drain-Source On-Voltage ( $V_{GS} = 10 \text{ V}, I_D = 10 \text{ A}$ )	$V_{DS(on)}$	—	—	5.0	Vdc
Forward Transconductance ( $V_{DS} = 10 \text{ V}, I_D = 5.0 \text{ A}$ )	$g_{fs}$	5.0	7.0	—	mhos

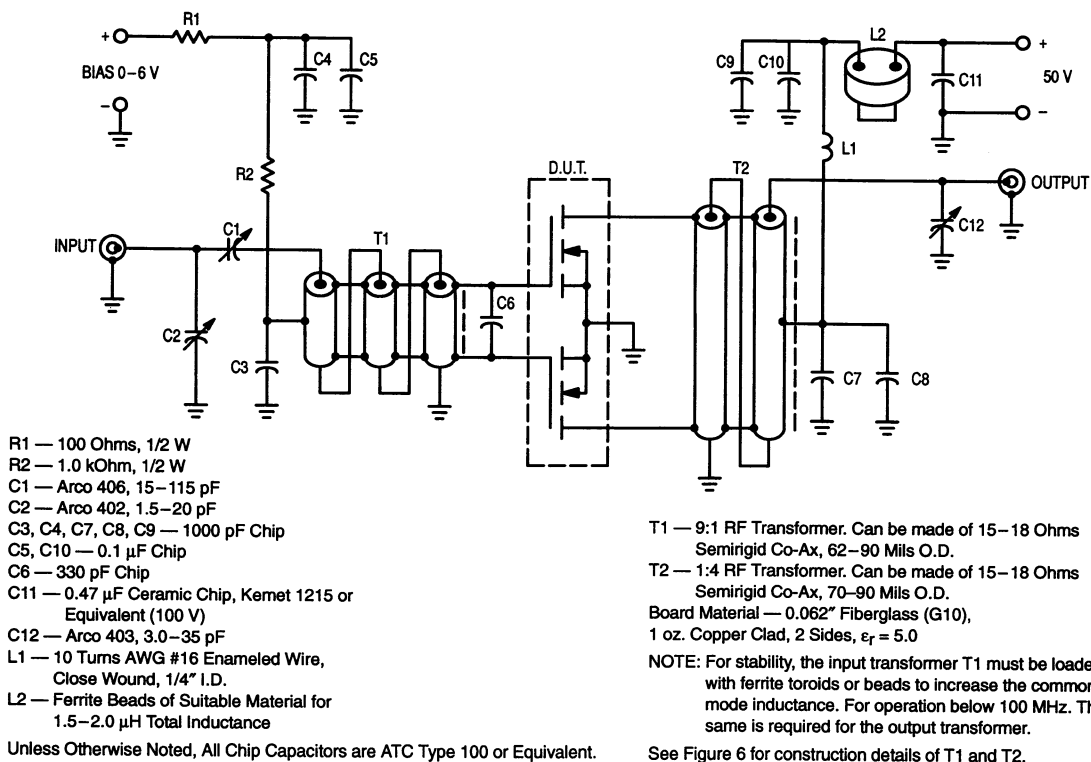
**DYNAMIC CHARACTERISTICS (Each Side)**

Input Capacitance ( $V_{DS} = 50 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{iss}$	—	350	—	pF
Output Capacitance ( $V_{DS} = 50 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{oss}$	—	225	—	pF
Reverse Transfer Capacitance ( $V_{DS} = 50 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	$C_{rss}$	—	20	—	pF

**FUNCTIONAL TESTS**

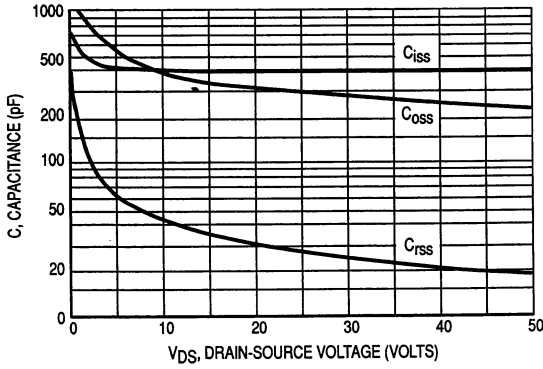
Common Source Amplifier Power Gain ( $V_{DD} = 50 \text{ V}, P_{out} = 300 \text{ W}, I_{DQ} = 500 \text{ mA}, f = 175 \text{ MHz}$ )	$G_{ps}$	14	16	—	dB
Drain Efficiency ( $V_{DD} = 50 \text{ V}, P_{out} = 300 \text{ W}, f = 175 \text{ MHz}, I_D (\text{Max}) = 11 \text{ A}$ )	$\eta$	50	55	—	%
Load Mismatch ( $V_{DD} = 50 \text{ V}, P_{out} = 300 \text{ W}, I_{DQ} = 500 \text{ mA},$ VSWR 5:1 at all Phase Angles)	$\psi$	No Degradation in Output Power			

2



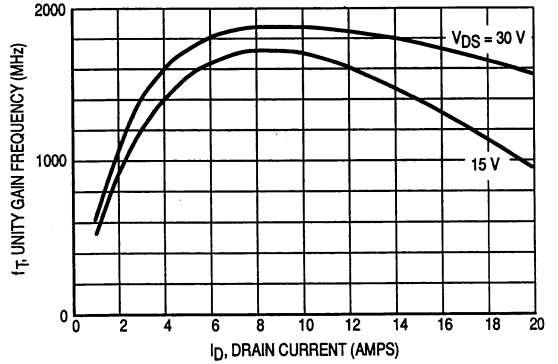
**Figure 1. 175 MHz Test Circuit**

## TYPICAL CHARACTERISTICS

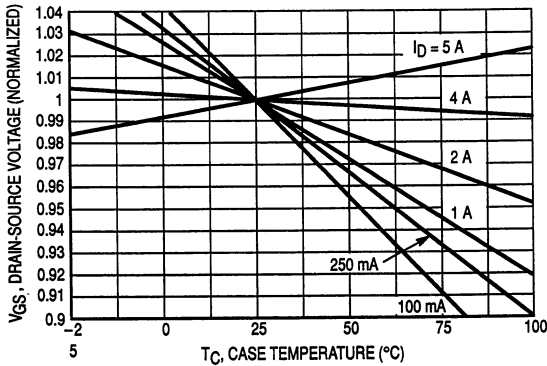


**Figure 2. Capacitance versus Drain-Source Voltage\***

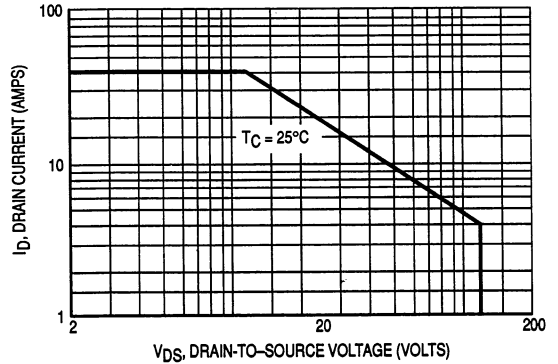
\*Data shown applies to each half of MRF151G.



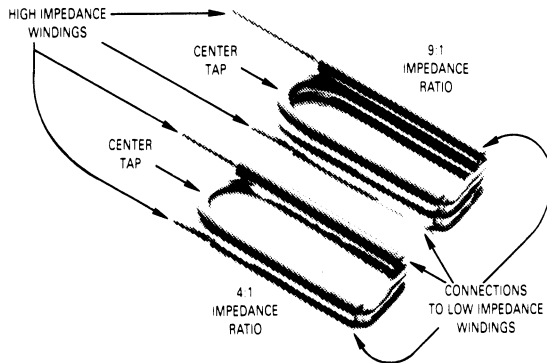
**Figure 3. Common Source Unity Gain Frequency versus Drain Current\***



**Figure 4. Gate-Source Voltage versus Case Temperature\***



**Figure 5. DC Safe Operating Area**



**Figure 6. RF Transformer**

## TYPICAL CHARACTERISTICS

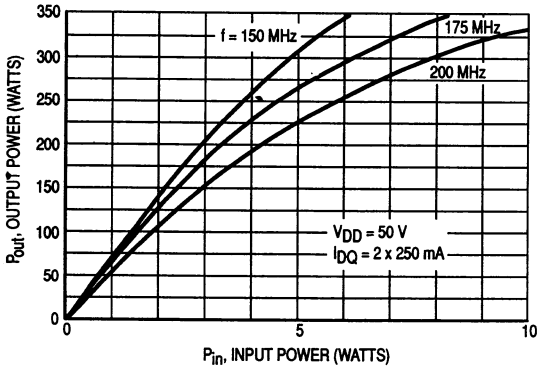


Figure 7. Output Power versus Input Power

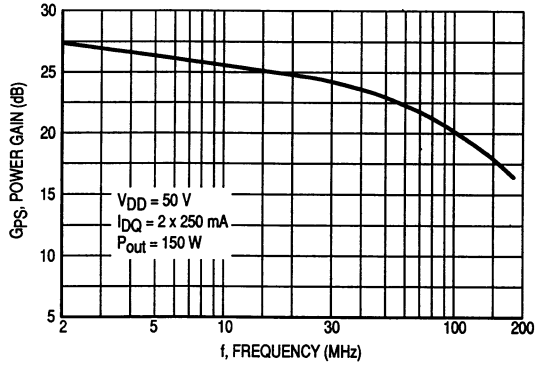
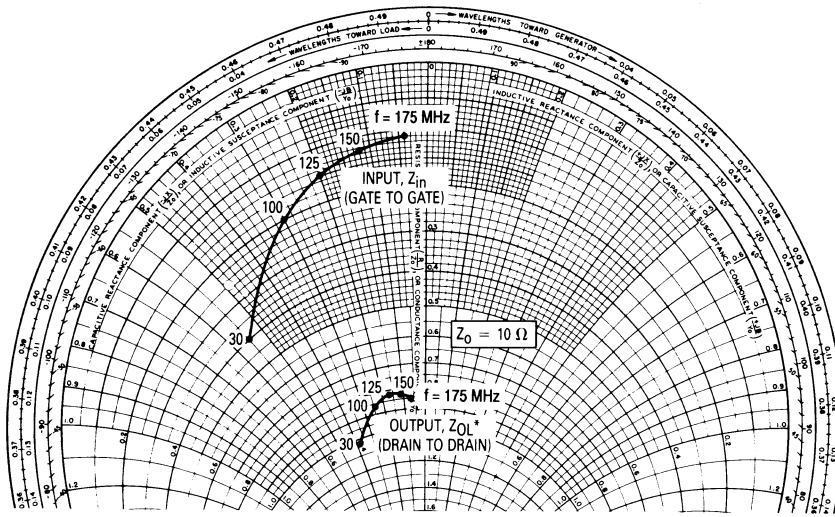


Figure 8. Power Gain versus Frequency



$Z_{OL}^*$  = Conjugate of the optimum load impedance into which the device output operates at a given output power, voltage and frequency.

Figure 9. Input and Output Impedance

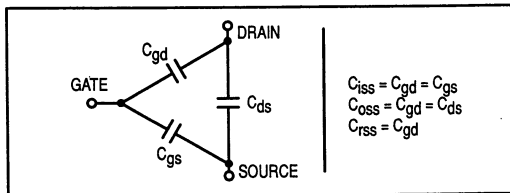
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### MOSFET CAPACITANCES

The physical structure of a MOSFET results in capacitors between the terminals. The metal anode gate structure determines the capacitors from gate-to-drain ( $C_{gd}$ ), and gate-to-source ( $C_{gs}$ ). The PN junction formed during the fabrication of the RF MOSFET results in a junction capacitance from drain-to-source ( $C_{ds}$ ).

These capacitances are characterized as input ( $C_{iss}$ ), output ( $C_{oss}$ ) and reverse transfer ( $C_{rss}$ ) capacitances on data sheets. The relationships between the inter-terminal capacitances and those given on data sheets are shown below. The  $C_{iss}$  can be specified in two ways:

1. Drain shorted to source and positive voltage at the gate.
2. Positive voltage of the drain in respect to source and zero volts at the gate. In the latter case the numbers are lower. However, neither method represents the actual operating conditions in RF applications.



### LINEARITY AND GAIN CHARACTERISTICS

In addition to the typical IMD and power gain data presented, Figure 3 may give the designer additional information on the capabilities of this device. The graph represents the small signal unity current gain frequency at a given drain current level. This is equivalent to  $f_T$  for bipolar transistors. Since this test is performed at a fast sweep speed, heating of the device does not occur. Thus, in normal use, the higher temperatures may degrade these characteristics to some extent.

### DRAIN CHARACTERISTICS

One figure of merit for a FET is its static resistance in the full-on condition. This on-resistance,  $V_{DS(on)}$ , occurs in the linear region of the output characteristic and is specified under specific test conditions for gate-source voltage and drain current. For MOSFETs,  $V_{DS(on)}$  has a positive temperature coefficient and constitutes an important design consideration at high temperatures, because it contributes to the power dissipation within the device.

### GATE CHARACTERISTICS

The gate of the MOSFET is a polysilicon material, and is electrically isolated from the source by a layer of oxide. The input resistance is very high — on the order of  $10^9$  ohms — resulting in a leakage current of a few nanoamperes.

Gate control is achieved by applying a positive voltage slightly in excess of the gate-to-source threshold voltage,  $V_{GS(th)}$ .

**Gate Voltage Rating** — Never exceed the gate voltage rating. Exceeding the rated  $V_{GS}$  can result in permanent damage to the oxide layer in the gate region.

**Gate Termination** — The gates of these devices are essentially capacitors. Circuits that leave the gate open-

cuted or floating should be avoided. These conditions can result in turn-on of the devices due to voltage build-up on the input capacitor due to leakage currents or pickup.

**Gate Protection** — These devices do not have an internal monolithic zener diode from gate-to-source. If gate protection is required, an external zener diode is recommended.

Using a resistor to keep the gate-to-source impedance low also helps damp transients and serves another important function. Voltage transients on the drain can be coupled to the gate through the parasitic gate-drain capacitance. If the gate-to-source impedance and the rate of voltage change on the drain are both high, then the signal coupled to the gate may be large enough to exceed the gate-threshold voltage and turn the device on.

### HANDLING CONSIDERATIONS

When shipping, the devices should be transported only in antistatic bags or conductive foam. Upon removal from the packaging, careful handling procedures should be adhered to. Those handling the devices should wear grounding straps and devices not in the antistatic packaging should be kept in metal tote bins. MOSFETs should be handled by the case and not by the leads, and when testing the device, all leads should make good electrical contact before voltage is applied. As a final note, when placing the FET into the system it is designed for, soldering should be done with a grounded iron.

### DESIGN CONSIDERATIONS

The MRF151G is an RF Power, MOS, N-channel enhancement mode field-effect transistor (FET) designed for HF and VHF power amplifier applications.

Motorola Application Note AN211A, FETs in Theory and Practice, is suggested reading for those not familiar with the construction and characteristics of FETs.

The major advantages of RF power MOSFETs include high gain, low noise, simple bias systems, relative immunity from thermal runaway, and the ability to withstand severely mismatched loads without suffering damage. Power output can be varied over a wide range with a low power dc control signal.

### DC BIAS

The MRF151G is an enhancement mode FET and, therefore, does not conduct when drain voltage is applied. Drain current flows when a positive voltage is applied to the gate. RF power FETs require forward bias for optimum performance. The value of quiescent drain current ( $I_{DQ}$ ) is not critical for many applications. The MRF151G was characterized at  $I_{DQ} = 250$  mA, each side, which is the suggested minimum value of  $I_{DQ}$ . For special applications such as linear amplification,  $I_{DQ}$  may have to be selected to optimize the critical parameters.

The gate is a dc open circuit and draws no current. Therefore, the gate bias circuit may be just a simple resistive divider network. Some applications may require a more elaborate bias system.

### GAIN CONTROL

Power output of the MRF151G may be controlled from its rated value down to zero (negative gain) by varying the dc gate voltage. This feature facilitates the design of manual gain control, AGC/ALC and modulation systems.